



US00D870390S

(12) **United States Design Patent**
Mao

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(54) **MASK**

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(**) Term: **15 Years**

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(51) **LOC (12) Cl.** **29-02**

(52) **U.S. Cl.**
USPC **D29/108; D24/110.1**

(58) **Field of Classification Search**
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D29/122; D2/878, 880, 881; D24/110.1;
2/455, 456, 410, 423, 424, 425.9, 171,
2/173, 206, 207, 906; 128/857, 858,
128/201.22, 201.23, 201.24, 206.21
CPC .. A42B 3/18; A42B 3/185; A42B 3/20; A42B
3/32; A42B 3/322; A42B 3/00; A63B
71/10; A63B 2071/105; A61F 9/04; A61F
9/045; A61F 9/06
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

3,132,345	A *	5/1964	Keith	A42B 3/08 2/9
3,196,458	A *	7/1965	Keith	A63B 71/10 2/9
D277,520	S *	2/1985	Gregory	D24/110.1
4,653,124	A *	3/1987	McNeal	A61F 9/029 128/206.21
D407,858	S *	4/1999	Cyr	D29/108
D518,242	S *	3/2006	Wright	D29/108
D518,605	S *	4/2006	Chen	D29/108
D522,179	S *	5/2006	Wright	D29/108
D522,697	S *	6/2006	Chen	D29/108

D558,403	S *	12/2007	Lee	D29/108
D589,211	S *	3/2009	Stevens	D29/110
D636,128	S *	4/2011	Hancock	D29/108
D665,903	S *	8/2012	Sullivan, Jr.	D24/110.1
D671,688	S *	11/2012	Sullivan, II	A41D 13/1146 D29/108
D767,754	S *	9/2016	Danford	D24/110.1
9,643,048	B1 *	5/2017	Danford	A61M 16/20
9,707,444	B1 *	7/2017	Danford	A63B 23/18
D803,482	S *	11/2017	Greenblat	D29/108
D811,581	S *	2/2018	Danford	D24/110.1
9,914,017	B2 *	3/2018	McKeown	A63B 21/4003
D819,194	S *	5/2018	Wenger	D24/110.1
D820,434	S *	6/2018	Bergman	D24/110.1
D820,974	S *	6/2018	Danford	D24/110.1
D826,478	S	8/2018	Chen	
D833,682	S *	11/2018	Greenblat	D29/108
D838,836	S *	1/2019	Liu	D24/110.1
D850,760	S *	6/2019	Greenblat	D2/865
10,322,312	B1 *	6/2019	Danford	A63B 23/18

(Continued)

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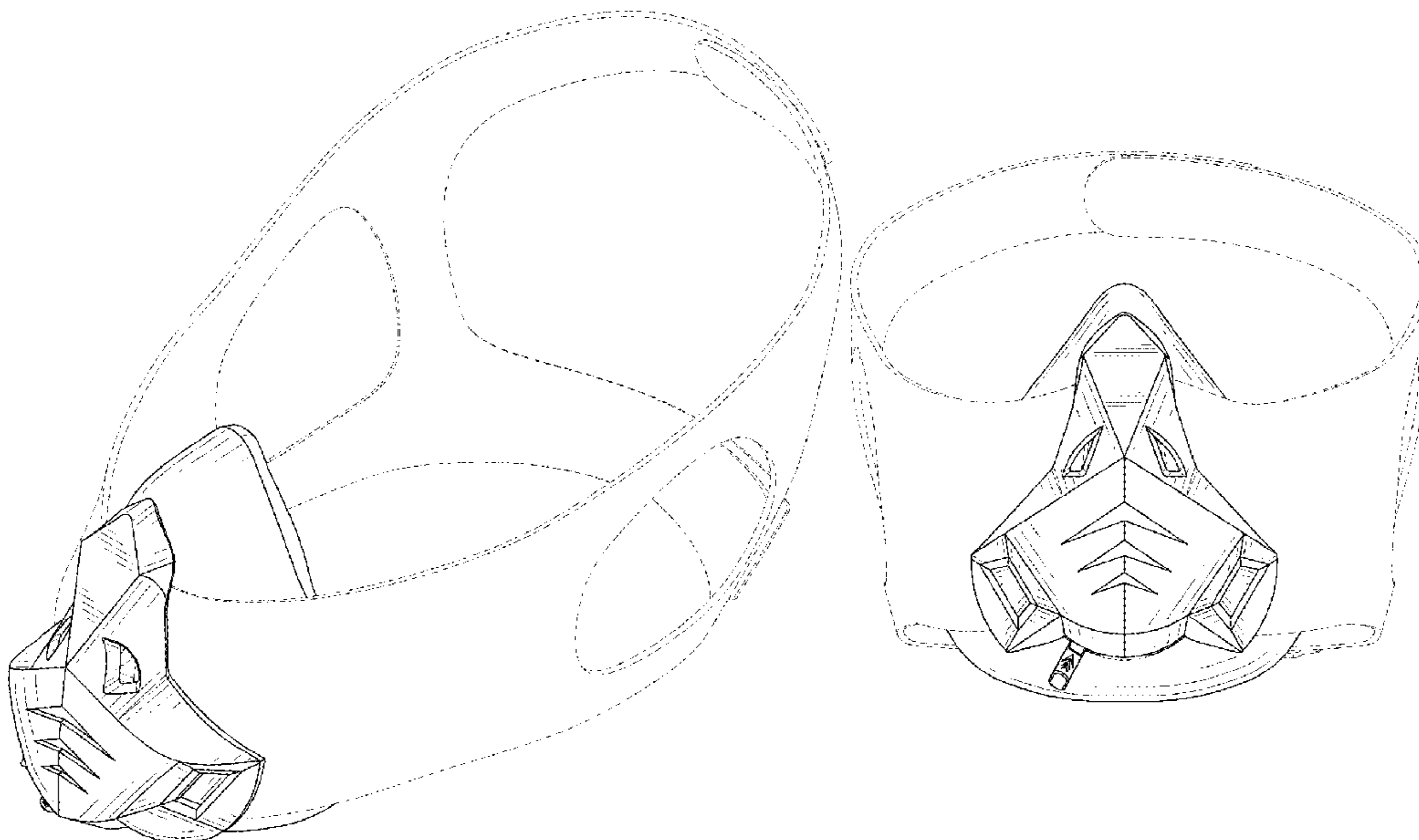
(57) **CLAIM**

The ornamental design for a mask, as shown and described.

DESCRIPTION

FIG. 1 is a top perspective view of a mask, showing my new design;
 FIG. 2 is a bottom perspective view thereof;
 FIG. 3 is a front view thereof;
 FIG. 4 is a back view thereof;
 FIG. 5 is a left side view thereof;
 FIG. 6 is a right side view thereof;
 FIG. 7 is a top view thereof; and,
 FIG. 8 is a bottom view thereof.
 The broken lines in the figures illustrate portions of the mask that form no part of the claimed design. The broken lines in the figures indicate the environmental structure that form no part of the claimed design.

1 Claim, 8 Drawing Sheets



(56)

References Cited

U.S. PATENT DOCUMENTS

2011/0203593 A1* 8/2011 Ishigami A62B 23/025
128/206.13
2015/0053206 A1* 2/2015 Seppala A62B 18/025
128/202.27
2017/0144000 A1* 5/2017 Danford A62B 7/10

* cited by examiner

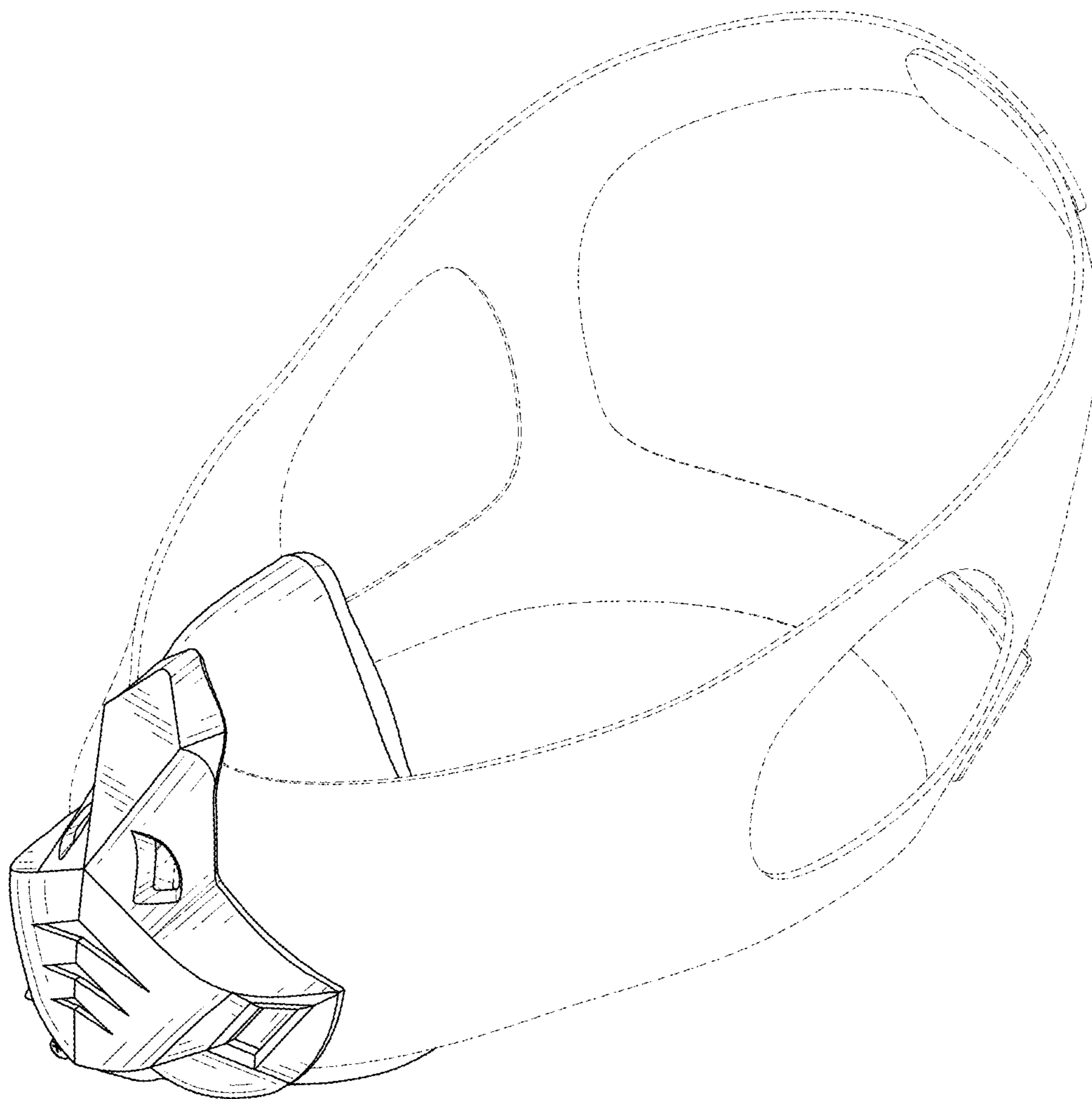


FIG. 1

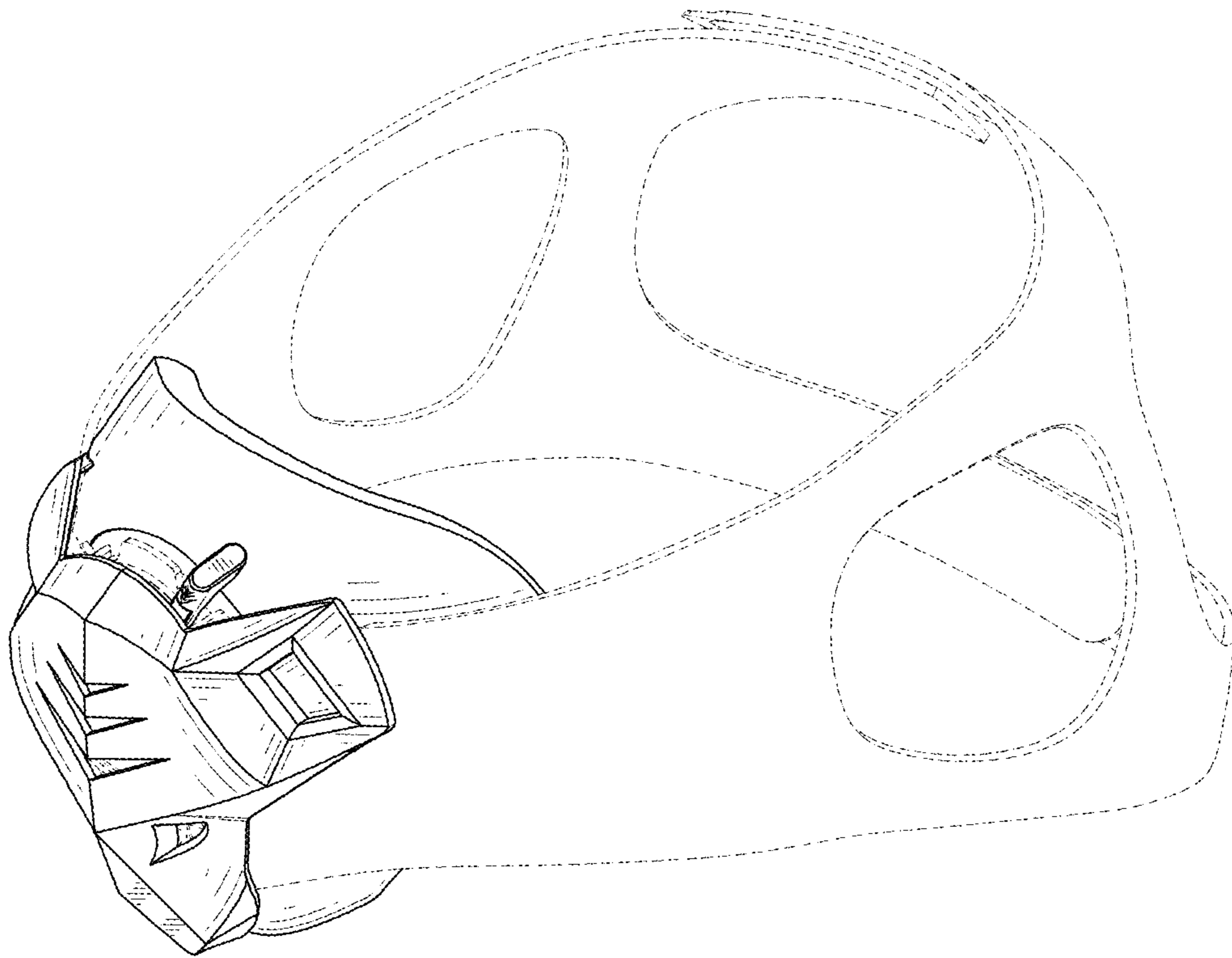


FIG. 2

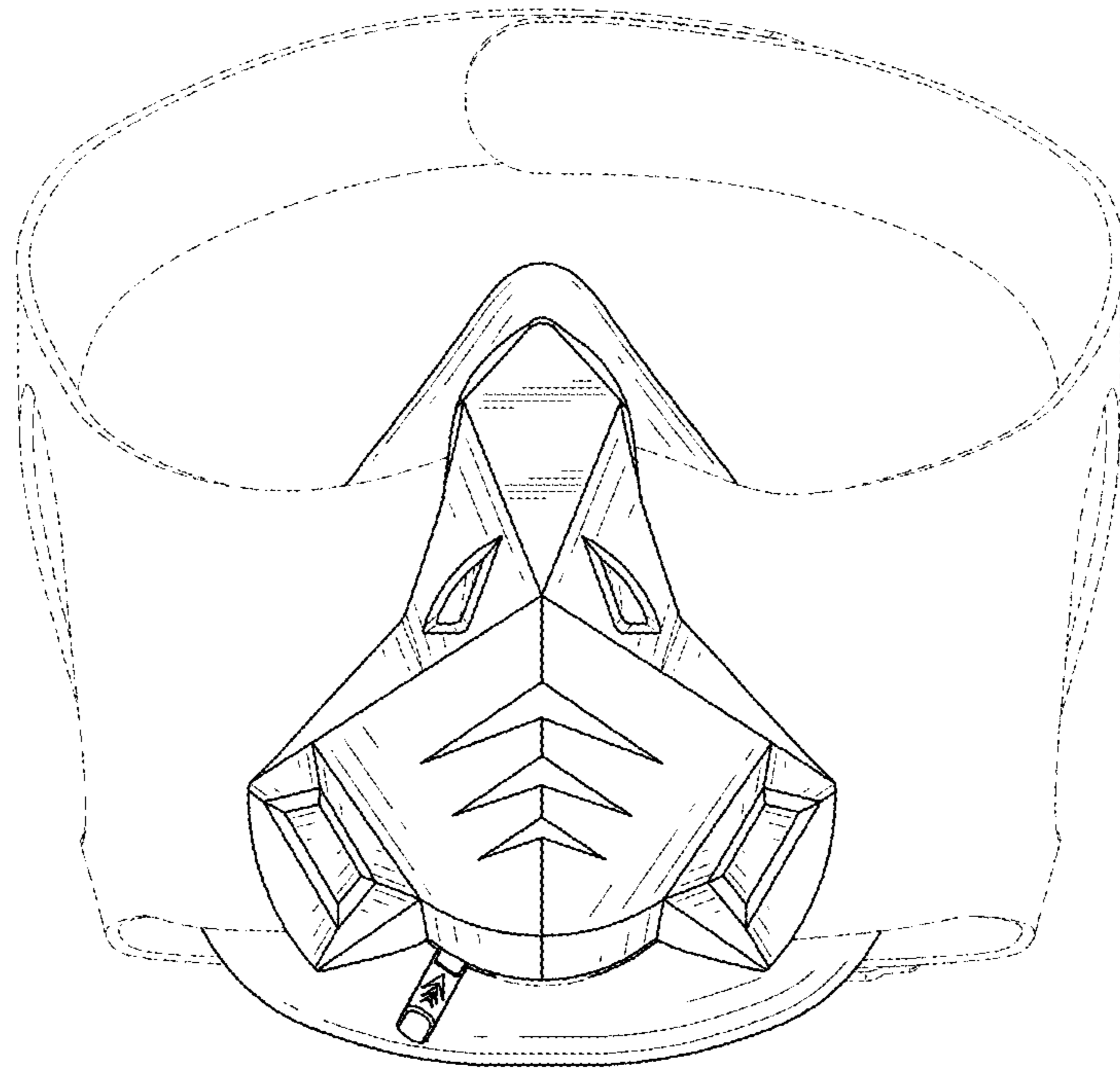


FIG. 3

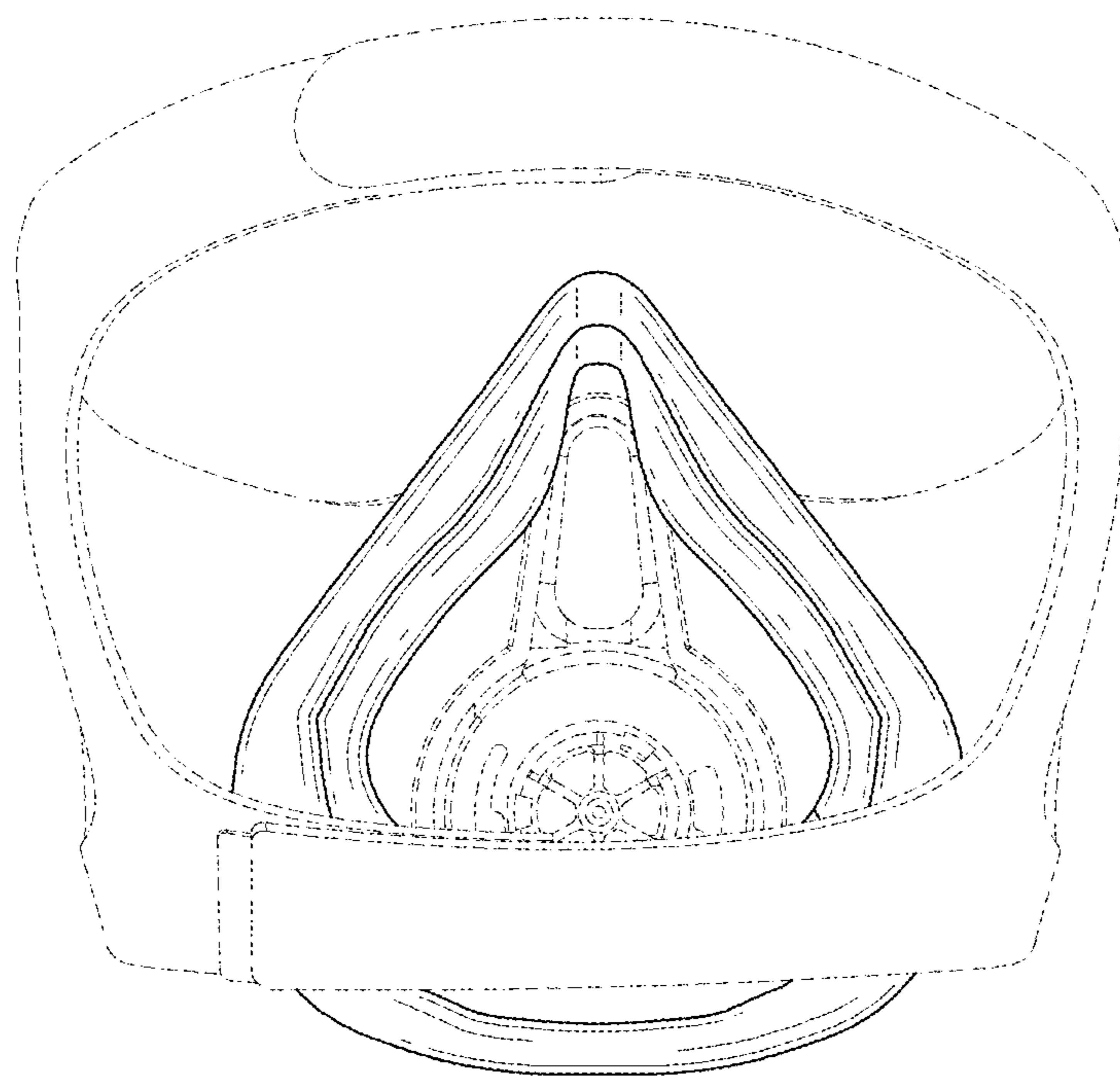


FIG. 4

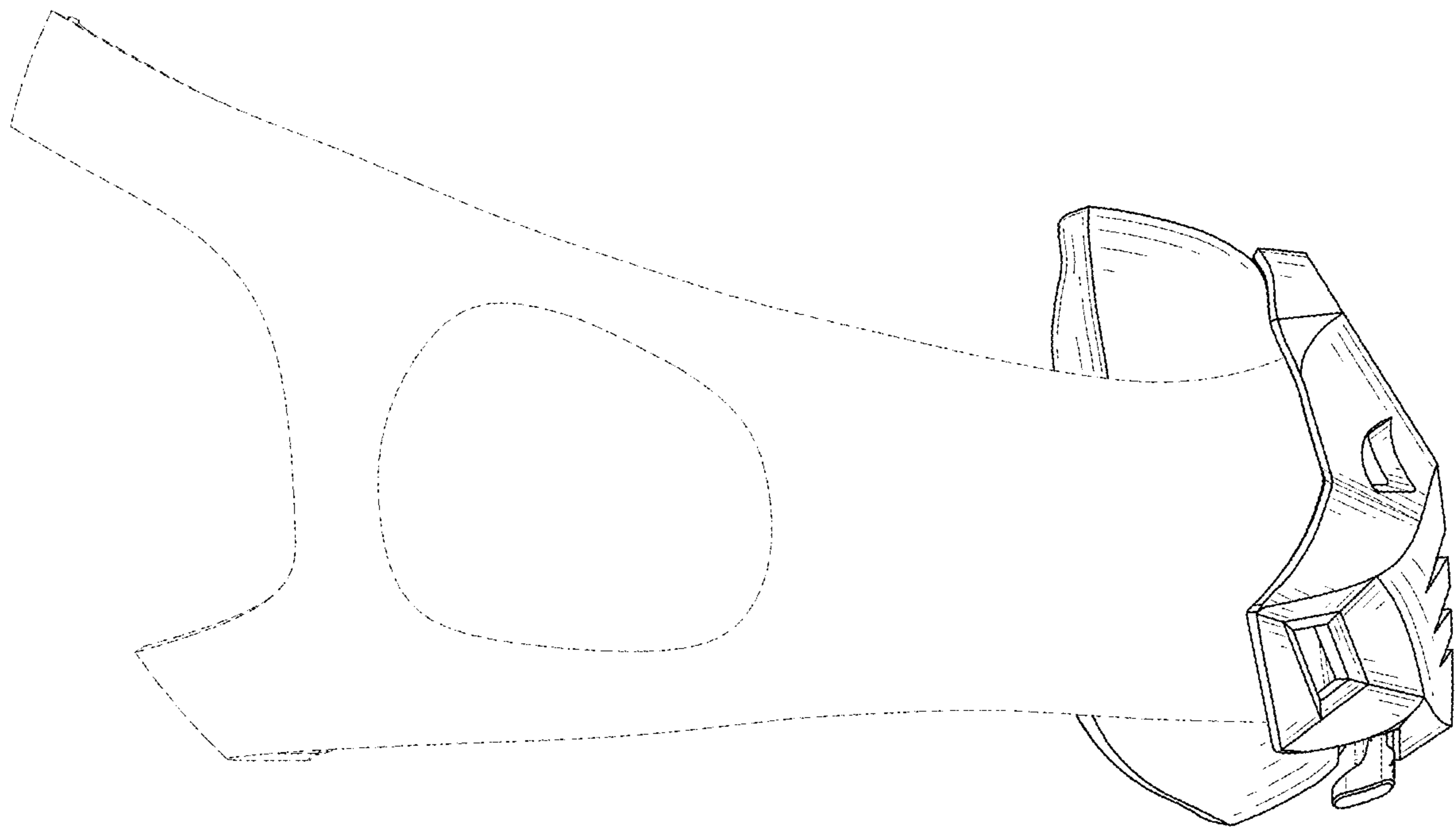


FIG. 5

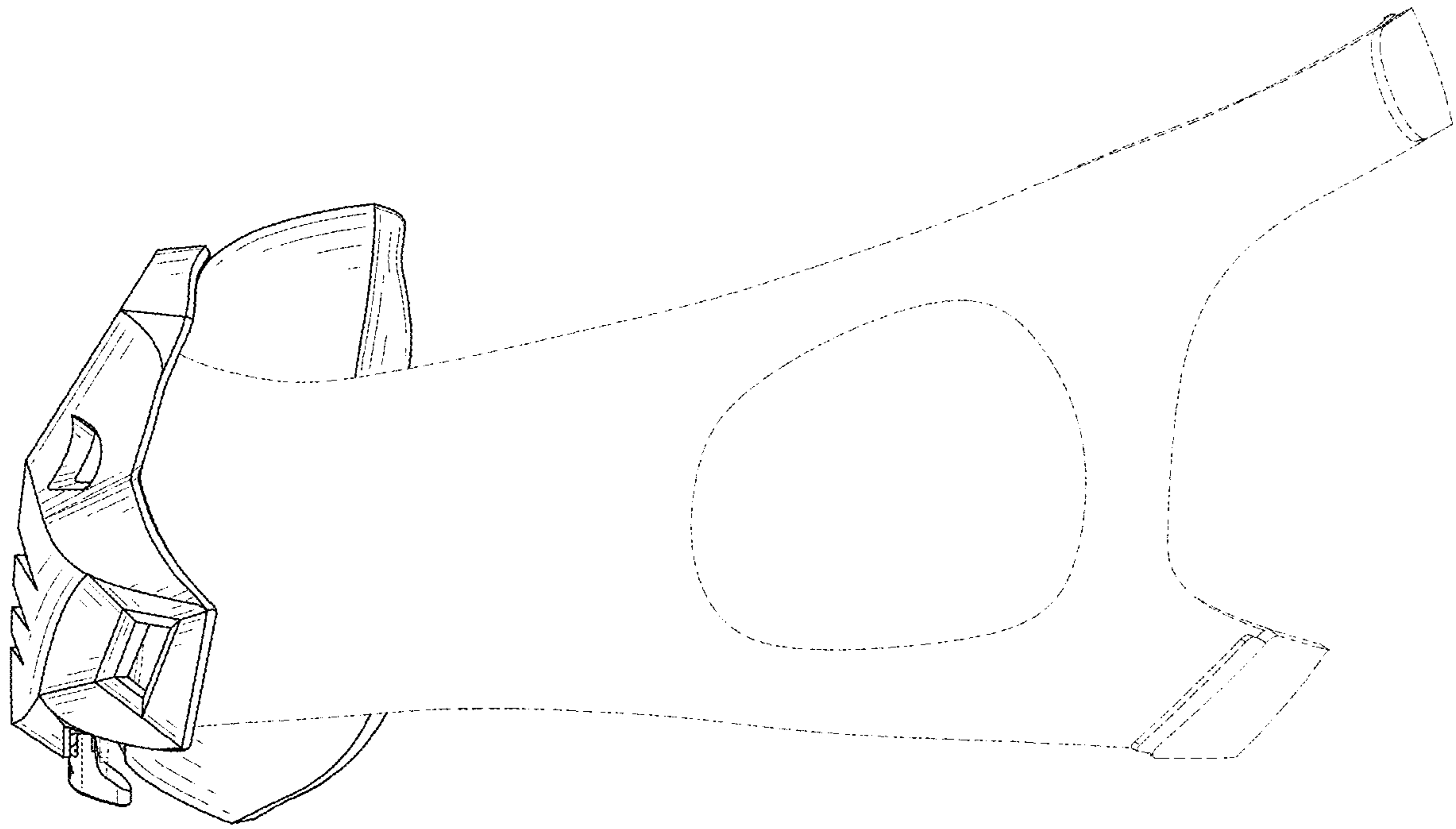


FIG. 6

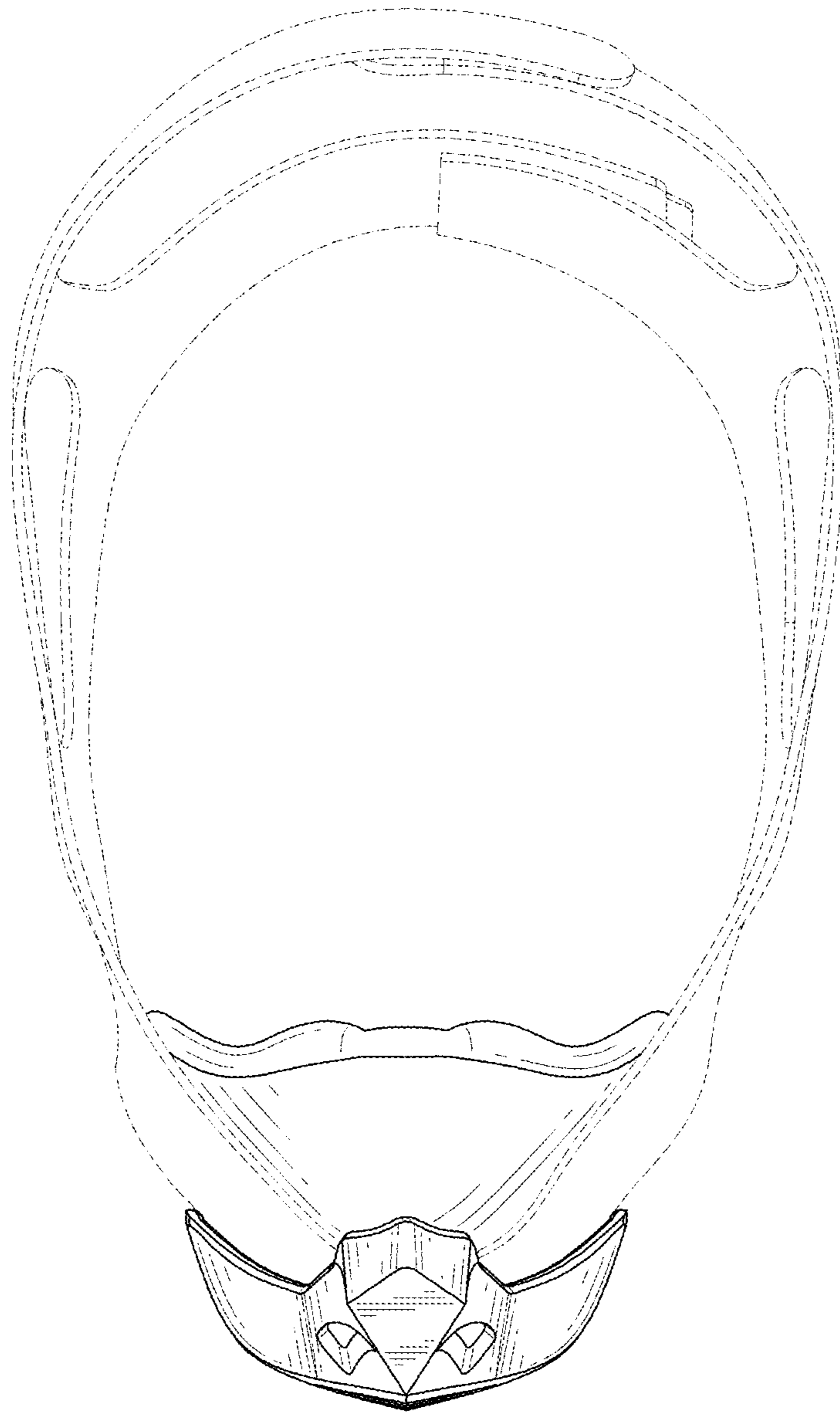


FIG. 7

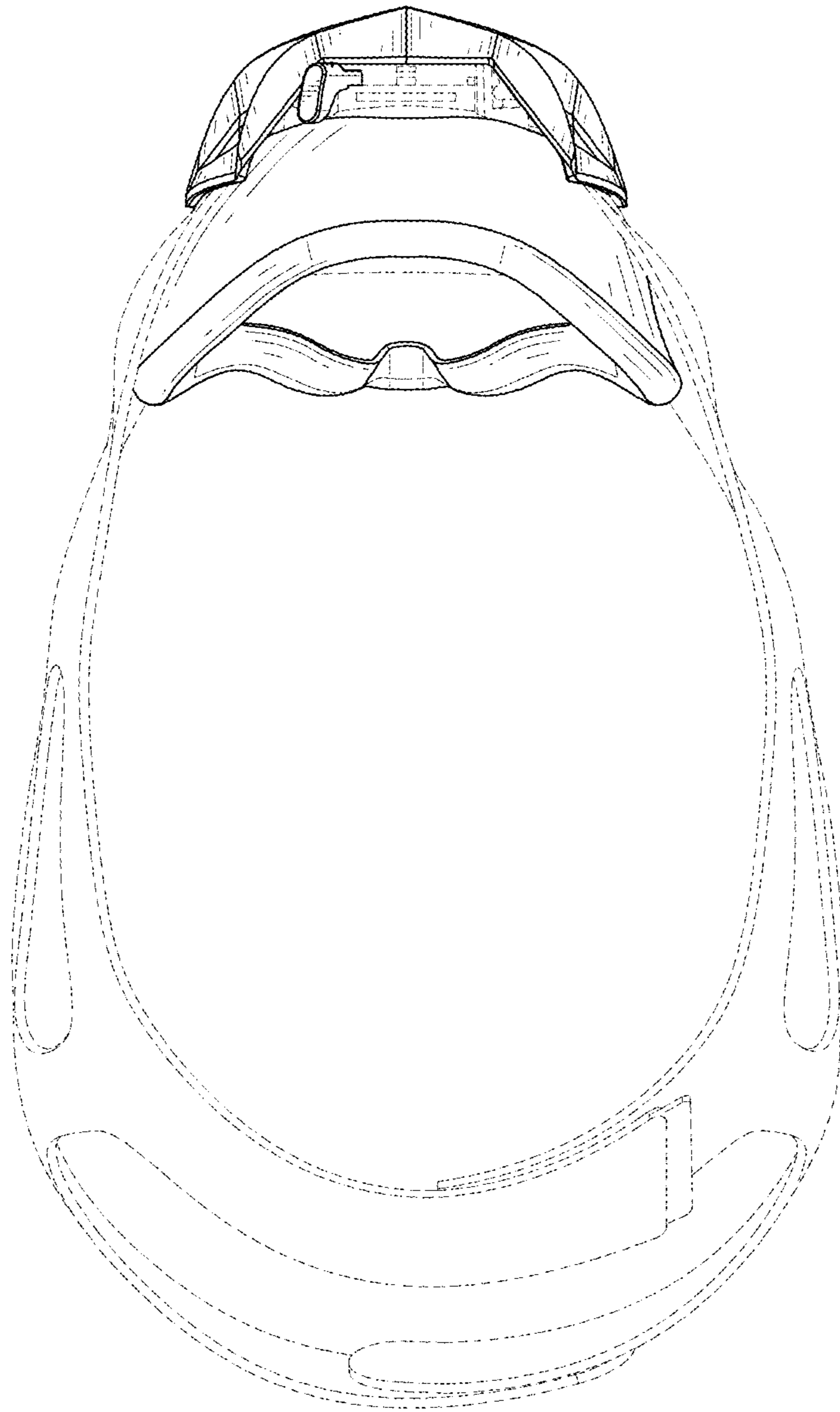


FIG. 8